

Title (en)

METHOD FOR COATING APPARATUSES AND PARTS OF APPARATUSES USED IN CHEMICAL MANUFACTURING

Title (de)

VERFAHREN ZUR BESCHICHTUNG VON APPARATEN UND APPARATETEILEN FÜR DEN CHEMISCHEN ANLAGENBAU

Title (fr)

PROCEDE POUR APPLIQUER UN REVETEMENT SUR DES APPAREILS OU DES PARTIES D'APPAREILS UTILISES POUR LA CONSTRUCTION D'INSTALLATIONS CHIMIQUES

Publication

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Application

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Abstract (en)

[origin: DE19860526A1] The invention relates to a method for coating a reactor. Said method is characterised in that a metal layer or a metal polymer dispersion layer is deposited on the inner surface of the reactor in a currentless manner by contacting the surfaces to a metal electrolytic solution which contains a reduction means and a halogenated polymer in dispersed form in addition to the metal electrolyte. Said halogenated polymer can optionally be deposited.

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